

Attorney Docket No.:
UNTD-0001 (122302.00001)

PATENT

IFW/



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Oliver Chyan and Thomas Ponnuswamy

Serial No.: 10/600,039

Filed: June 20, 2003

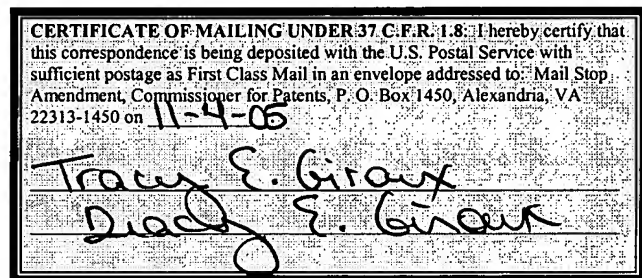
Art Unit: 2818

Examiner: Dung Anh Le

For: **METHOD OF MAKING INTEGRATED CIRCUITS USING
RUTHENIUM AND ITS OXIDES AS A CU DIFFUSION BARRIER**

Mail Stop Amendment
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Sir:



AMENDMENT UNDER 37 C.F.R. §1.111

Responsive to the Office Action dated July 5, 2005, having a shortened statutory period for response expiring October 5, 2005, and extended for one month by petition enclosed herewith until November 5, 2005, please amend the above-identified patent application as follows: